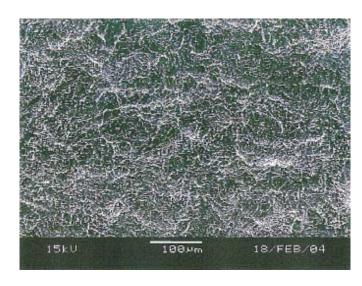
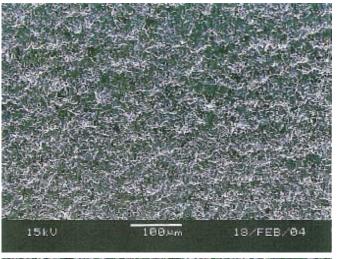


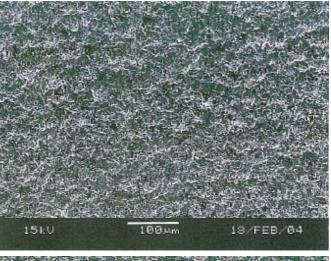
# X 200 (Surface from above)



(coated platinum)



**NEXUS** plate



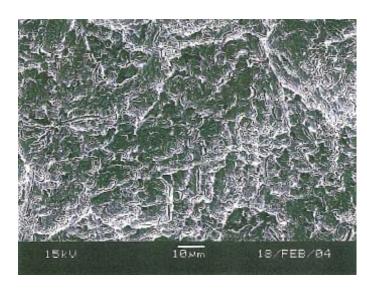
15kU 100 Mm 18/FEB/04

D company Dipping method

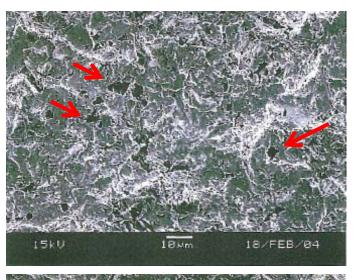
H company Dipping method



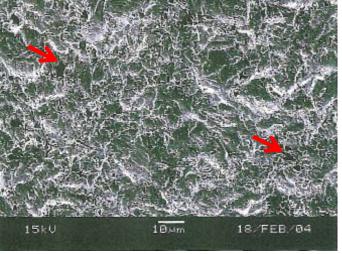
## X 1000 (Surface from above)



NEXUS plate (coated platinum)



D company Dipping method

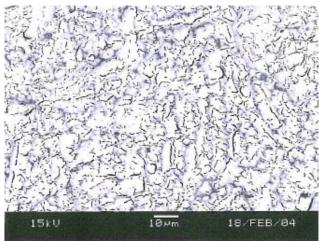


H company Dipping method

The Red arrows area is not coated platinum area.

## X 1000 (Platinum rate)

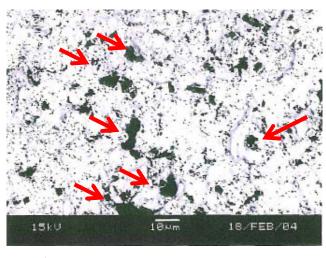
#### The rate of platinum SEM image



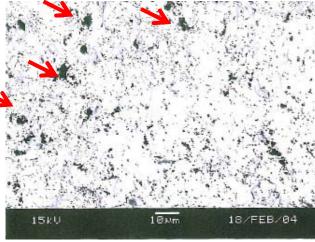
NEXUS plate (coated platinum)

Our plate have full platinum by spray method.

#### Not enough to attach the platinum

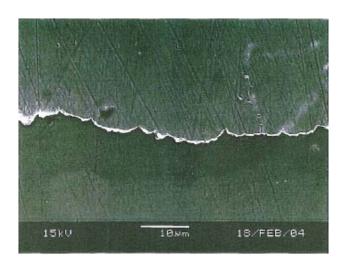


D company Dipping method



H company Dipping method

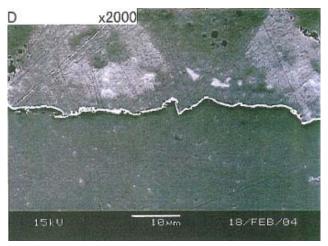
## X 2000 (Cross section)



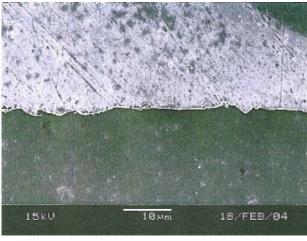
NEXUS plate (coated platinum)

The plate surface is very rough so the rate of area very large better than other plates.

The plate surface is shown flat plate. So the rate of area small.

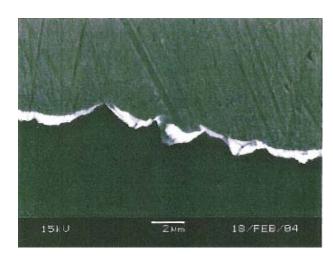


D company Dipping method



H company Dipping method

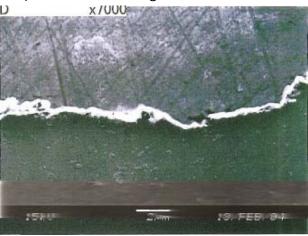
### X 7000 (Cross section)



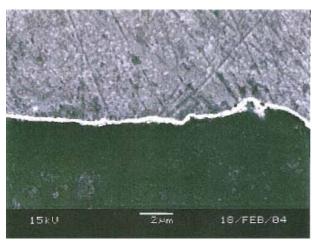
NEXUS plate (coated platinum)

The plate surface is very rough so the rate of area very large better than other plates.

The plate surface is shown flat plate. So the rate of area small. Also the platinum not enough to be coated on the plate.



D company Dipping method

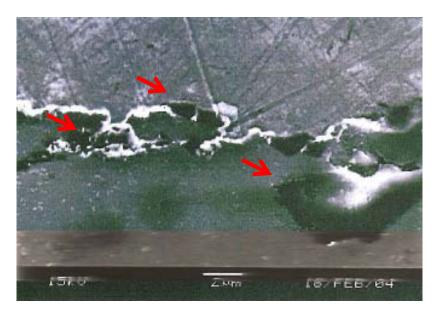


H company Dipping method

## X 2000 (Cross section)



X 6000 (Cross section)



D/H company Dipping method

D/H company Dipping method

When the plate are made by dipping, there are some dust, the area is not be coated for dust. So when you look the image, find out a black area.

### 電極比較試験(入水流量別試験)

Electric rate

入水流量 Water flow	設定段数	電解電圧		電解電流		PH		ORP(mv)	
		Coated	Plated	Coated	Plated	Coated	Plated	Coated	Plated
	アルかり水1段	3.10	3.65	0.18	0.18	9.03	9.20	-104	-23
	アルカリ水2段	4.65	4.80	0.31	0.28	9.40	9.54	-252	-108
1.2 I/min	アルカリ水3段	6.40	6.80	0.45	0.44	9.83	9.84	-300	-207
Low	アルカリ水4段	8.00	9.00	0.70	0.82	9.99	10.21	-334	-370
	酸性水	12.25	12.50	1.10	1.10	6.30	5.60	726	603
	アルカリ水1段	4.50	4.60	0.33	0.25	9.03	8.99	-27	24
	アルカリ水2段	6.60	6.72	0.56	0.50	9.42	9.38		-79
2.0 I/min	アルカリ水3段	9.90	10.20	0.90	0.89	9.76	9.69	-342	-200
Medium	アルカリ水4段	22.00	22.50	2.35	2.40	10.40	10.30	-482	-440
	酸性水	23.00	23.70	2.28	2.58	5.66	5.80	The state of the s	520
	アルカリ水1段	5.60	5.65	0.42	0.35	9.04	9.03		48
	アルカリ水2段	8.70	8.50	0.78	0.61	9.38	9.35	Commence of the commence of th	-52
2.8 I/min	アルカリ水3段	13.80	13.70	1.45	1.21	9.72	6.59	The second control of the control of	-219
High	アルカリ水4段	34.60	33.80	3.78	3.80	10.38	10.24	THE RESERVE AND ADDRESS OF THE PARTY.	-467
	酸性水	33.00	34.80	3.70	4.20	5.63		773	269

原水: PH7.2、ORP 508mv Tap Water; pH7.2 / ORP 508mV

This information indicate the pH and ORP high better than Dipping method plates.

In Low water flow, pH and ORP is high than Coated plate(NEXUS plate).

But medium flow and high flow, the measurement high than Dipping plate.

Also the ORP is very high than Dipping plate.

<sup>◎</sup>工配訊駅は現仕工産中のION-IOO>室を用いて行い、電圧、電流に乗吊か無いか確認する為で、 結果はそのまま適用可能である事を確認した。